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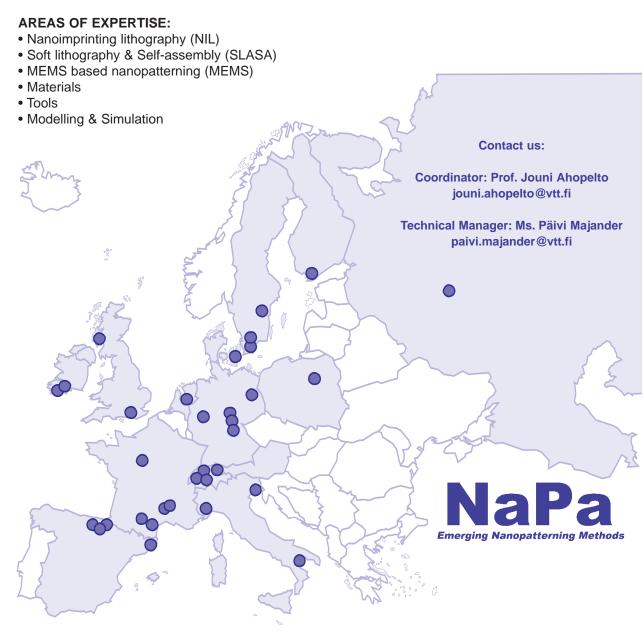












FACTS:

- FP6 Integrated Project
- NMP Thematic Priority
- Duration 48 months (March 2004 February 2008)
- Total volume 31 M€ (funded by EU and partners themselves)
- Contract nº: NMP4-CT-2003-500120
- Consortium composed of 35 teams from 14 countries

TRAINING & DISSEMINATION:

- PANAMA summer schools
- NaPa focused conference sessions
- WEB site
- Newsletters
- Flyers

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